PERMIT APPLICATION GENERAL INSTRUCTIONS INDUSTRIAL USER BASELINE MONITORING REPORT (BMR)

1. The Information requested in the enclosed form is mandated under City of Philadelphia's Wastewater Regulations and/or Federal Clean Water Regulations.

GENERAL INSTRUCTIONS

2. Please complete the attached form and return it within 30 days to the following address:

Philadelphia Water Department Industrial Waste & Backflow Compliance 1101 Market Street, 6th Floor Philadelphia, PA 19107

If you have any Questions, please contact the following Person(s):

Ms. Jennifer L. Moore (215) 685-6085

SPECIFIC INSTRUCTIONS

- Item 1. A.-N. Provide all requested information about the facility.
- <u>Item 2.</u> A.-B. Provide a listing of all raw materials and chemicals used in the facility's operations. Avoid use of trade names of chemicals. If trade names are used, provide information regarding the active ingredients including the MSDS.
 - C. Please describe each process in sufficient detail: Use additional sheets if necessary.
 - D. List each component process, the production rate (i.e., (product name) #/year), as well as the SIC code for each process.
- Item 3. A. Provide the total plant flow rate (average and maximum) to the sanitary sewer in gallons per day (GPD). If accurate flow measurements are unavailable, provide the best estimate.

 Mark "estimated" if this method is used.
 - B. Provide a breakdown of the sources of the total plant flow to the sanitary sewer including process flows, sanitary wastewater, cooling water, etc. Also indicate the flow rate (GPD) and the type of discharge (batch, continuous or none).
 - C. In order to provide City with a complete understanding of the facility's processes, location of pretreatment facilities and sampling points, the discharger is required to submit a schematic of each process and a schematic of wastewater flows. Flow rates may be estimated. Be sure to indicate sample locations on the flow or process schematic.
 - Item 4. A. The facility must provide information on or sample, analyze and report the concentration of all pollutants. If no in-house sampling is performed fill in the results from any sampling performed by the Water Department. All samples must be representative of normal operations and be of sufficient number to allow process evaluation. Samples should be collected immediately after the named process (after treatment, if applicable. or "end of pipe") before being combined with other wastestreams. Type of sample (i.e., grab, composite), sample location, number of samples and methods of analysis should be adequately described. If analytical data is provided for more than one sampling point, identify the location of all sampling points in the schematic diagram required in Question 3D above.
 - B. If the facility is unable to sample the wastewater before being mixed with other wastewater flows, the facility may sample the total plant flow and calculate an equivalent concentration limit using the combined wastestream formula. The combined wastestream formula will be applied by the Water Department in instances where the samples taken include wastewater from diluting streams (i.e. sanitary flow).
- <u>Item 5&6.</u> Self-explanatory. If pretreatment of wastewater is performed, provide full details. If no pretreatment is used, it should also be clearly indicated.
- Item 7. This report must be signed by an authorized representative, which may include a principal executive officer of at least the level of vice president; a general partner or proprietor; or a duly authorized representative that is responsible for the overall operation of the facility.

PERMIT APPLICATIONINDUSTRIAL USER BASELINE MONITORING REPORT (BMR)

<u>Instructions:</u> Please complete this Form in as much detail as possible. Use additional sheets as necessary. Refer to General Instructions. Return the Form to the address shown in the instructions.

OMPANY INFORMATION		
A. Legal Name:		B. Facility Name:
Mailing Address:		Location:
	Zip	Zip
	Z.ip	<u>~</u>
C. Name or Owner(s):	D.	Name of Operator(s)
E. Phone Number	F.	Fax Number
G. Facility Contact (provide the reto contact if additional information		er, and e-mail address of a designated person
		J. Number of Days of Operation Per Hours of operation of pretreatment_
M. Operating At This Location S	ince(mm/dd	/yy)
-	e from this facility. (If the	rks (sewage authority, municipality, etc.) that his facility is not connected to a sewage
ATTITUDE OF OPEN ATION		
ATURE OF OPERATION		
A. List Raw Materials Used. Incl	ude Average & Maximi	ım Used per Day: (Include MSDS)
B. List of Chemicals Used: (Inclu	ude MSDS)	
-		nd Processes Conducted and the Final
products: Use additional sheets to	o elaborate, if necessary.	
D. Summarize Each Component		
Process Description	Production Rates	Sic Code & Sub Part if Applicable

		d? YesN	(0 <u></u>)		
A. Total Plant F	low In Gallons Per	day (GPD) Av	erageMaxir	num	
B. Individual Process Flows in Gallons Per day (GPD)					
Component Process	Average Flow Rate (GPD)	Maximum Flow Rate (GPD)	Type of Discharge (Batch, Continuous, None) Time & Duration	Peak Flow Rate (30 Minute Duration)	
Cooling Water Sanitary Wastewater					
List any daily, n	nonthly and/or seas	onal variations	in flow if any		
C. List All Wate	er and/or Sewer Acc	count numbers.	(Provide a copy of a recent v	water/sewer bill.)	
D. Provide on a	separate sheet:				
	-	w chart of each	regulated process		
1) A schem	natic drawing or flo			egulated), location of	
1) A schem 2) A schem	natic drawing or flo	ing all wastewa	ter flows (regulated and unre	gulated), location of	
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Collected: Analytical Methods Used:

Does sample include wastewater from other non-process streams (such as sanitary water, non-contact cooling water), if so, what streams from those listed in Item #3 are Included?						
Provide a list of all materials which are or could be discharged						
5. WASTEWATER TREATMENT						
Fully describe any and all wastewater treatment utilized (show treatment system relation to process flows on schematic drawing required by Question 3.D)						
6. COMPLIANCE CERTIFICATION						
A. Is the facility meeting applicable categorical pretreatment standards on a cons YES NO	sistent basis?					
B. If no, do you require:						
 additional operation and maintenance (O&M) to achieve compliance? new or additional pretreatment equipment facilities to achieve compliance? 	YESNO YESNO					
Where additional pretreatment and/or O&M will be required to meet the Pretreatment	atment					

Standards, on a consistent basis, attach a schedule on a separate sheet. The completion date in this schedule shall not be later than the compliance date established for the applicable Pretreatment Standard.

The following conditions shall apply to this schedule:

- (1) The schedule shall contain increments of progress in the form of dates for the commencement and completion of major events leading to the construction and operation of additional pretreatment required for the User to meet the applicable Pretreatment Standards (e.g., completing preliminary plans, completing final plans, executing contract for major components, commencing construction, completing construction, etc.).
- (2) No increment referred to in paragraph (1) shall exceed 9 months.
- (3) Not later than 14 days following each date in the schedule and the final date for compliance, the User shall submit a progress report to the Department including, at a minimum, whether or not it complied with the increment of progress to be met on such date and, if not, the date on which it expects to comply with this increment of progress, the reason for delay, and the steps being taken by the User to return the construction to the schedule established. In no event shall more than nine (9) months elapse between such progress reports to the Department.

7. SIGNATORY REQUIREMENT

All applications, reports or information submitted to the city as required by this Permit shall be signed and certified by an authorized representative as specified at 40 CFR 403.12(1).

Any person signing a document shall make the following certification: -

"I certify under penalty of law that this document and all attachments were prepared under my direction or supervision In accordance with a system designed to assure that qualified personnel properly gather and evaluate the information submitted. Based on my inquiry of the person or persons who manage the system, or those persons directly responsible for gathering the information, the information submitted is, to the best of my knowledge and belief, true, accurate, and complete. I am aware that there are significant penalties for submitting false information, including the possibility of fine and imprisonment for knowing violations."

NAME - AUTHORIZED REPRESENTATIVE	SIGNATURE
OFFICIAL TITLE	DATE